Michal Bockowski

List of Publications by Year in descending order

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340 papers 6,720 citations

39 h-index 63 g-index

347 all docs

347 docs citations

times ranked

347

3926 citing authors

| # | Article | IF | CITATIONS |
|----|--|-----|-----------|
| 1 | Investigation of beryllium diffusion in HVPE-GaN grown in [11–20] and [10-10] crystallographic directions. Materials Science in Semiconductor Processing, 2022, 139, 106332. | 4.0 | 3 |
| 2 | The effect of annealing on photoluminescence from defects in ammonothermal GaN. Journal of Applied Physics, 2022, 131, . | 2.5 | 12 |
| 3 | Thermal annealing of GaN implanted with Be. Journal of Applied Physics, 2022, 131, . | 2.5 | 7 |
| 4 | Carbon and Manganese in Semi-Insulating Bulk GaN Crystals. Materials, 2022, 15, 2379. | 2.9 | 9 |
| 5 | Recent Progress in Crystal Growth of Bulk GaN. Acta Physica Polonica A, 2022, 141, 167-174. | 0.5 | 2 |
| 6 | Electrical transport properties of highly doped N-type GaN materials. Semiconductor Science and Technology, 2022, 37, 055012. | 2.0 | 6 |
| 7 | On Stress-Induced Polarization Effect in Ammonothermally Grown GaN Crystals. Crystals, 2022, 12, 554. | 2.2 | 4 |
| 8 | Atomic-scale investigation of implanted Mg in GaN through ultra-high-pressure annealing. Journal of Applied Physics, 2022, 131, . | 2.5 | 8 |
| 9 | Effect of Ultraâ€Highâ€Pressure Annealing on Defect Reactions in Ionâ€Implanted GaN Studied by Positron Annihilation. Physica Status Solidi (B): Basic Research, 2022, 259, . | 1.5 | 7 |
| 10 | Fundamental Studies on Crystallization and Reaching the Equilibrium Shape in Basic Ammonothermal Method: Growth on a Native Lenticular Seed. Materials, 2022, 15, 4621. | 2.9 | 1 |
| 11 | Volume relaxation in a borosilicate glass hot compressed by three different methods. Journal of the American Ceramic Society, 2021, 104, 816-823. | 3.8 | 2 |
| 12 | Structural densification of lithium phosphoaluminoborate glasses. Journal of the American Ceramic Society, 2021, 104, 1345-1359. | 3.8 | 7 |
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| 14 | Suppressing the lateral growth during HVPE-GaN crystallization in the c-direction. Journal of Crystal Growth, 2021, 556, 125986. | 1.5 | 3 |
| 15 | Mg-implanted bevel edge termination structure for GaN power device applications. Applied Physics Letters, 2021, 118, . | 3.3 | 20 |
| 16 | X-ray photoelectron spectroscopy study on effects of ultra-high-pressure annealing on surface of Mg-ion-implanted GaN. Japanese Journal of Applied Physics, 2021, 60, 036503. | 1.5 | 4 |
| 17 | Defect-related photoluminescence from ammono GaN. Journal of Applied Physics, 2021, 129, 095703. | 2.5 | 8 |
| 18 | Isochronal annealing study of Mg-implanted p-type GaN activated by ultra-high-pressure annealing. Applied Physics Express, 2021, 14, 056501. | 2.4 | 14 |

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| 19 | Bond Switching in Densified Oxide Glass Enables Record-High Fracture Toughness. ACS Applied Materials & Samp; Interfaces, 2021, 13, 17753-17765. | 8.0 | 31 |
| 20 | Thermal conductivity of densified borosilicate glasses. Journal of Non-Crystalline Solids, 2021, 557, 120644. | 3.1 | 9 |
| 21 | Indentation Response of Calcium Aluminoborosilicate Glasses Subjected to Humid Aging and Hot Compression. Materials, 2021, 14, 3450. | 2.9 | 1 |
| 22 | Design and demonstration of nearly-ideal edge termination for GaN p–n junction using Mg-implanted field limiting rings. Applied Physics Express, 2021, 14, 074002. | 2.4 | 19 |
| 23 | Carbon complexes in highly C-doped GaN. Physical Review B, 2021, 104, . | 3.2 | 18 |
| 24 | Structural Analysis of Low Defect Ammonothermally Grown GaN Wafers by Borrmann Effect X-ray Topography. Materials, 2021, 14, 5472. | 2.9 | 17 |
| 25 | Effects of the sequential implantation of Mg and N ions into GaN for p-type doping. Applied Physics Express, 2021, 14, 111001. | 2.4 | 12 |
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| 30 | A Deep Carbonâ€Related Acceptor Identified through Photoâ€Induced Electron Paramagnetic Resonance. Physica Status Solidi (B): Basic Research, 2020, 257, 1900593. | 1.5 | 1 |
| 31 | Study of Dislocations in Homoepitaxially and Heteroepitaxially Grown AlN Layers. Physica Status Solidi (A) Applications and Materials Science, 2020, 217, 2000465. | 1.8 | 3 |
| 32 | Synchrotron X-ray topography characterization of high quality ammonothermal-grown gallium nitride substrates. Journal of Crystal Growth, 2020, 551, 125903. | 1.5 | 17 |
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| 39 | High Pressure Processing of Ion Implanted GaN. Electronics (Switzerland), 2020, 9, 1380. | 3.1 | 36 |
| 40 | Progress on and challenges of p-type formation for GaN power devices. Journal of Applied Physics, 2020, 128, . | 2.5 | 54 |
| 41 | Impacts of high temperature annealing above $1400 \hat{A}^\circ$ C under N2 overpressure to activate acceptors in Mg-implanted GaN. , 2020, , . | | 6 |
| 42 | Impact of impurity-based phonon resonant scattering on thermal conductivity of single crystalline GaN. Applied Physics Letters, 2020, 117, 082101. | 3.3 | 7 |
| 43 | GaN Single Crystalline Substrates by Ammonothermal and HVPE Methods for Electronic Devices. Electronics (Switzerland), 2020, 9, 1342. | 3.1 | 18 |
| 44 | Defect evolution in Mg ions implanted GaN upon high temperature and ultrahigh N2 partial pressure annealing: Transmission electron microscopy analysis. Journal of Applied Physics, 2020, 127, . | 2.5 | 38 |
| 45 | Acceptor state anchoring in gallium nitride. Applied Physics Letters, 2020, 116, . | 3.3 | 2 |
| 46 | Investigation of diffusion mechanism of beryllium in GaN. Physica B: Condensed Matter, 2020, 594, 412316. | 2.7 | 8 |
| 47 | Strain Recovery and Defect Characterization in Mgâ€Implanted Homoepitaxial GaN on Highâ€Quality GaN Substrates. Physica Status Solidi (B): Basic Research, 2020, 257, 1900705. | 1.5 | 14 |
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| 51 | Revisiting the Dependence of Poisson's Ratio on Liquid Fragility and Atomic Packing Density in Oxide Glasses. Materials, 2019, 12, 2439. | 2.9 | 30 |
| 52 | Synchrotron radiation X-ray topography and defect selective etching analysis of threading dislocations in halide vapor phase epitaxy GaN crystal grown on ammonothermal seed. Japanese Journal of Applied Physics, 2019, 58, SCCB19. | 1.5 | 4 |
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| 55 | Electric-field-induced simultaneous diffusion of Mg and H in Mg-doped GaN prepared using ultra-high-pressure annealing. Applied Physics Express, 2019, 12, 111005. | 2.4 | 24 |
| 56 | V-shaped dislocations in a GaN epitaxial layer on GaN substrate. AIP Advances, 2019, 9, . | 1.3 | 8 |
| 57 | Highly effective activation of Mg-implanted p-type GaN by ultra-high-pressure annealing. Applied Physics Letters, 2019, 115, . | 3.3 | 110 |
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| 64 | Incorporation of Carbon in Free-Standing HVPE-Grown GaN Substrates. Journal of Electronic Materials, 2019, 48, 2226-2232. | 2.2 | 17 |
| 65 | Luminescence behaviour of Eu3+ in hot-compressed silicate glasses. Journal of Non-Crystalline Solids: X, 2019, 4, 100041. | 1.2 | 3 |
| 66 | Multifold pressure-induced increase of electric conductivity in LiFe0.75V0.10PO4 glass. Scientific Reports, 2019, 9, 16607. | 3.3 | 8 |
| 67 | Study of spectral and recombination characteristics of HVPE GaN grown on ammono substrates. Materials Science in Semiconductor Processing, 2019, 91, 341-355. | 4.0 | 8 |
| 68 | Foam glass obtained through highâ€pressure sintering. Journal of the American Ceramic Society, 2018, 101, 3917-3923. | 3.8 | 20 |
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| 71 | Pressure-induced structural changes in titanophosphate glasses studied by neutron and X-ray total scattering analyses. Journal of Non-Crystalline Solids, 2018, 483, 50-59. | 3.1 | 13 |
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| 73 | Eu–Mg defects and donor–acceptor pairs in GaN: photodissociation and the excitation transfer problem. Journal Physics D: Applied Physics, 2018, 51, 065106. | 2.8 | 5 |
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| 81 | Doping in bulk HVPE-GaN grown on native seeds – highly conductive and semi-insulating crystals. Journal of Crystal Growth, 2018, 499, 1-7. | 1.5 | 28 |
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| 121 | Challenges and future perspectives in HVPE-GaN growth on ammonothermal GaN seeds. Semiconductor Science and Technology, 2016, 31, 093002. | 2.0 | 116 |
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| 139 | Determination of an acceptor level in bulk GaN grown by high nitrogen pressure solution method. Physica Status Solidi (B): Basic Research, 2015, 252, 923-927. | 1.5 | 5 |
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| 148 | Homoepitaxial HVPE GaN growth on non- and semi-polar seeds. Proceedings of SPIE, 2015, , . | 0.8 | 4 |
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| 161 | Examination of growth rate during hydride vapor phase epitaxy of GaN on ammonothermal GaN seeds. Journal of Crystal Growth, 2014, 407, 52-57. | 1.5 | 21 |
| 162 | Composition-Structure-Property Relations of Compressed Borosilicate Glasses. Physical Review Applied, 2014, 2, . | 3.8 | 47 |

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